

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Janusz Murakowski et al.

Confirmation No.: 1853

Application No.: 10/707,854

Filed: January 16, 2004

Art Unit: 2823

For: ETCHLESS FABRICATION OF PLANAR
PHOTONIC CRYSTAL STRUCTURES IN
HIGH REFRACTIVE INDEX MATERIAL

Examiner: F. L. Toledo

AMENDMENT AFTER FINAL REJECTION

MS AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

August 15, 2006

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Final Office Action mailed August 8, 2006, the following Amendments and remarks are submitted to place the above-identified U.S. patent application in condition for allowance.

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.

No fees are believed to be due with this Amendment after Final.